

NS6130-10-1022



Quick Facts

Product	:	Zr/Cu/Al/Ag Sputtering Target
Stock No	:	NS6130-10-1022
Purity	:	>99.9%
Molecular Formula	:	ZrCuAlAg

Zirconium Copper

ALUMINIUM SILVER

Alloy Sputtering Target

Technical Specification

Diameter	Thickness
50.8 mm ± 1mm	3 mm ± 0.5mm

Zirconium, copper, aluminum, silver (ZrCuAlAg) alloy sputtering target is a specialized material used in the production of thin films in the semiconductor and electronics industries. ZrCuAlAg alloy sputtering target is a specialized material with unique properties that make it valuable in the production of thin films for a variety of applications in the semiconductor and electronics industries. zirconium, copper, aluminum, silver (ZrCuAlAg) alloy sputtering target useful in a variety of other applications, such as in the production of solar cells and other optoelectronic devices.



* This image is for graphic purposes only and does not represent the actual product.



ISO 9001:2015
CERTIFIED COMPANY

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